

	Hits	Search Text
1	84	plasma and ((duty adj cycle) same bias)
2	25	(on near modulat\$4) puls\$4 near bias\$3 and RF near bias\$3 and plasma and etch\$3
3	21	((on near modulat\$4) puls\$4 near bias\$3 and RF near bias\$3 and plasma and etch\$3) not (plasma and ((duty adj cycle) same bias))
4	22	((("5110407") or ("5505778") or ("5401357") or ("5462635") or ("5895586") or ("5891252") or ("6033481") or ("5140272") or ("5108778") or ("5241186") or ("5284544") or ("5314839") or ("5402635") or ("5462635") or ("5874013") or ("5962347") or ("6074958") or ("4985114") or ("5352324") or ("5658811") or ("5868854") or ("5445709") or ("5766498")).PN.
5	58305	plasma and etch\$3
6	71	(plasma and etch\$3) and bias\$3 and vpp
7	117	(plasma and etch\$3) and bias\$3 and "v.sub.p"
8	46	(plasma and etch\$3) and bias\$3 and "v.sub.pp"
9	298	bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage)
10	119	(plasma and etch\$3) and (bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage))
11	323	((plasma and etch\$3) and bias\$3 and vpp) ((plasma and etch\$3) and bias\$3 and "v.sub.p") ((plasma and etch\$3) and bias\$3 and "v.sub.pp") ((plasma and etch\$3) and (bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage)))
12	84	plasma and ((duty adj cycle) same bias)
13	21	((on near modulat\$4) puls\$4 near bias\$3 and RF near bias\$3 and plasma and etch\$3) not (plasma and ((duty adj cycle) same bias))
14	317	((((plasma and etch\$3) and bias\$3 and vpp) ((plasma and etch\$3) and bias\$3 and "v.sub.p") ((plasma and etch\$3) and bias\$3 and "v.sub.pp") ((plasma and etch\$3) and (bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage)))) not ((plasma and ((duty adj cycle) same bias)) ((on near modulat\$4) puls\$4 near bias\$3 and RF near bias\$3 and plasma and etch\$3) not (plasma and ((duty adj cycle) same bias))))
15	4	(plasma and etch\$3) and (bias near (non-continuous intermittent interrupted))
16	17	(((((plasma and etch\$3) and bias\$3 and vpp) ((plasma and etch\$3) and bias\$3 and "v.sub.p") ((plasma and etch\$3) and bias\$3 and "v.sub.pp") ((plasma and etch\$3) and (bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage)))) not ((plasma and ((duty adj cycle) same bias)) ((on near modulat\$4) puls\$4 near bias\$3 and RF near bias\$3 and plasma and etch\$3) not (plasma and ((duty adj cycle) same bias)))) and RF adj bias\$3
17	22	(((((plasma and etch\$3) and bias\$3 and vpp) ((plasma and etch\$3) and bias\$3 and "v.sub.p") ((plasma and etch\$3) and bias\$3 and "v.sub.pp") ((plasma and etch\$3) and (bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage)))) not ((plasma and ((duty adj cycle) same bias)) ((on near modulat\$4) puls\$4 near bias\$3 and RF near bias\$3 and plasma and etch\$3) not (plasma and ((duty adj cycle) same bias)))) and RF near bias\$3
18	22	(((((plasma and etch\$3) and bias\$3 and vpp) ((plasma and etch\$3) and bias\$3 and "v.sub.p") ((plasma and etch\$3) and bias\$3 and "v.sub.pp") ((plasma and etch\$3) and (bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage)))) not ((plasma and ((duty adj cycle) same bias)) ((on near modulat\$4) puls\$4 near bias\$3 and RF near bias\$3 and plasma and etch\$3) not (plasma and ((duty adj cycle) same bias)))) and RF adj bias\$3) (((((plasma and etch\$3) and bias\$3 and vpp) ((plasma and etch\$3) and bias\$3 and "v.sub.p") ((plasma and etch\$3) and bias\$3 and "v.sub.pp") ((plasma and etch\$3) and (bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage)))) not ((plasma and ((duty adj cycle) same bias)) ((on near modulat\$4) puls\$4 near bias\$3 and RF near bias\$3 and plasma and etch\$3) not (plasma and ((duty adj cycle) same bias)))) and RF near bias\$3
19	323	((plasma and etch\$3) and bias\$3 and vpp) ((plasma and etch\$3) and bias\$3 and "v.sub.p") ((plasma and etch\$3) and bias\$3 and "v.sub.pp") ((plasma and etch\$3) and (bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage)))
20	207	(((((plasma and etch\$3) and bias\$3 and vpp) ((plasma and etch\$3) and bias\$3 and "v.sub.p") ((plasma and etch\$3) and bias\$3 and "v.sub.pp") ((plasma and etch\$3) and (bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage)))) and and "v.sub.pp") ((plasma and etch\$3) and (bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage)))) and
21	99	(((((plasma and etch\$3) and bias\$3 and vpp) ((plasma and etch\$3) and bias\$3 and "v.sub.p") ((plasma and etch\$3) and bias\$3 and "v.sub.pp") ((plasma and etch\$3) and (bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage)))) and and "v.sub.pp") ((plasma and etch\$3) and (bias\$3 and etch\$3 and ((peak-to-peak) (peak near peak) near voltage)))) and selectiv\$4) and (puls\$5 modulat\$4)
22	1247	etch\$3 and flat near bottom
23	394	etch\$3 same flat\$2 near bottom
24	52	(etch\$3 same flat\$2 near bottom) and etch\$3 near3 flat\$2 near bottom
25	0	((((etch\$3 same flat\$2 near bottom) and etch\$3 near3 flat\$2 near bottom) and bias\$3) and ((puls\$5 modulat\$3) near bias\$3)

	DBs
1	USPAT; EPO; JPO; DERWENT; IBM TDB
2	USPAT; EPO; JPO; DERWENT; IBM TDB
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26	10	((etch\$3 same flat\$2 near bottom) and etch\$3 near3 flat\$2 near bottom) and bias\$3
27	24	((etch\$3 same flat\$2 near bottom) and etch\$3 near3 flat\$2 near bottom) and etch\$3 near2 flat\$2 near bottom) not (((etch\$3 same flat\$2 near bottom) and etch\$3 near3 flat\$2 near bottom) and bias\$3)
28	8	((etch\$3 same flat\$2 near bottom) and etch\$3 near3 flat\$2 near bottom) and etch\$3 near2 flat\$2 near bottom) not (((etch\$3 same flat\$2 near bottom) and etch\$3 near3 flat\$2 near bottom) and bias\$3)) and etch\$3 near flat\$2 near bottom
29	16	((etch\$3 same flat\$2 near bottom) and etch\$3 near3 flat\$2 near bottom) and etch\$3 near2 flat\$2 near bottom) not (((etch\$3 same flat\$2 near bottom) and etch\$3 near3 flat\$2 near bottom) and bias\$3)) not (((etch\$3 same flat\$2 near bottom) and etch\$3 near3 flat\$2 near bottom) and etch\$3 near2 flat\$2 near bottom) not (((etch\$3 same flat\$2 near bottom) and etch\$3 near3 flat\$2 near bottom) and bias\$3)) and etch\$3 near flat\$2 near bottom
30	1712	plasma and etch\$3 and bias\$3 same (on?off puls\$5 modulat\$3 switch\$3)
31	110	(plasma and etch\$3 and bias\$3 same (on?off puls\$5 modulat\$3 switch\$3)) and (vpp "v.sub.pp" "v.sub.p" (volt\$3 near3 (peak-to-peak peak near peak)))
32	67	((plasma and etch\$3 and bias\$3 same (on?off puls\$5 modulat\$3 switch\$3)) and (vpp "v.sub.pp" "v.sub.p" (volt\$3 near3 (peak-to-peak peak near peak)))) and ("500" 500V 500volts)
33	0	((plasma and etch\$3 and bias\$3 same (on?off puls\$5 modulat\$3 switch\$3)) and (vpp "v.sub.pp" "v.sub.p" (volt\$3 near3 (peak-to-peak peak near peak)))) and ("500" 500V 500volts)) and ((vpp "v.sub.pp" "v.sub.p" peak-to-peak peak) near ("500" 500V 500volts))
34	20	((plasma and etch\$3 and bias\$3 same (on?off puls\$5 modulat\$3 switch\$3)) and (vpp "v.sub.pp" "v.sub.p" (volt\$3 near3 (peak-to-peak peak near peak)))) and ("500" 500V 500volts)) and ((vpp "v.sub.pp" "v.sub.p" peak-to-peak peak) same ("500" 500V 500volts))
35	39	((plasma and etch\$3 and bias\$3 same (on?off puls\$5 modulat\$3 switch\$3)) and (vpp "v.sub.pp" "v.sub.p" (volt\$3 near3 (peak-to-peak peak near peak)))) and ("800" 800V 800volts)
36	7	((plasma and etch\$3 and bias\$3 same (on?off puls\$5 modulat\$3 switch\$3)) and (vpp "v.sub.pp" "v.sub.p" (volt\$3 near3 (peak-to-peak peak near peak)))) and ("800" 800V 800volts)) and ((vpp "v.sub.pp" "v.sub.p" peak-to-peak peak) same ("800" 800V 800volts))
37	9	((plasma and etch\$3 and bias\$3 same (on?off puls\$5 modulat\$3 switch\$3)) and (vpp "v.sub.pp" "v.sub.p" (volt\$3 near3 (peak-to-peak peak near peak)))) and (duty adj (ratio cycle))
38	26	"2" and (("15" "14" "13" "12" "11" "10" "9" "8" "7" "6" "5" "4" "3" "2" "1") adj MHz)
39	4	((plasma and etch\$3 and bias\$3 same (on?off puls\$5 modulat\$3 switch\$3)) and (vpp "v.sub.pp" "v.sub.p" (volt\$3 near3 (peak-to-peak peak near peak)))) and (1??? 1???V 1???volts)
40	26	((plasma and etch\$3 and bias\$3 same (on?off puls\$5 modulat\$3 switch\$3)) and (vpp "v.sub.pp" "v.sub.p" (volt\$3 near3 (peak-to-peak peak near peak)))) and (("15" "14" "13" "12" "11" "10" "9" "8" "7" "6" "5" "4" "3" "2" "1") adj MHz)
41	34	((plasma and etch\$3 and bias\$3 same (on?off puls\$5 modulat\$3 switch\$3)) and (vpp "v.sub.pp" "v.sub.p" (volt\$3 near3 (peak-to-peak peak near peak)))) and ("micro." adj meter "micro.meter" micron)
42	86	((plasma and etch\$3 and bias\$3 same (on?off puls\$5 modulat\$3 switch\$3)) and (vpp "v.sub.pp" "v.sub.p" (volt\$3 near3 (peak-to-peak peak near peak)))) and (anisotrop\$5 selectiv\$3)

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